

10/07/2002  
10/07/2002  
02/11/02

PATENT NUMBER and  
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10073693	02/11/2002	430	270	1752	LEE, SJ.

**\*\*APPLICANTS:** Park Joohyeon; Seo Dongchul; Lee Jongbum; Jeon Hyunpyo; Kim Seongju;

**\*\*CONTINUING DATA VERIFIED:**

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**\*\* FOREIGN APPLICATIONS VERIFIED:**  
REPUBLIC OF KOREA 2001-29352 05/28/2001

PG-PUB ☐ DO NOT PUBLISH ☐

RESCIND ☐

Foreign priority claimed ☐ yes ☐ no  
35 USC 119 conditions met ☐ yes ☐ no  
Verified and Acknowledged Examiners's initials

ATTORNEY DOCKET NO

423.1036

**TITLE :** Polymer for chemically amplified resist and chemically amplified resist composition containing the same

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED		
			Total Claims	Print Claim for O.G.	
ISSUE FEE		Primary Examiner	DRAWING		
Amount Due	Date Paid		Sheets Drwg.	Figs. Drwg.	Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	Application Examiner		
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